



### PRODUCTION PROBER

# A200D

FULLY AUTOMATIC DOUBLE-SIDED





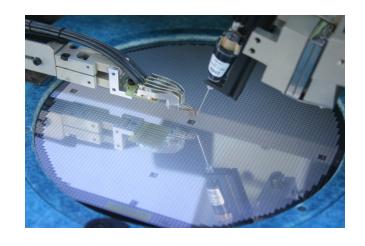
### KEY FEATURES



### SIMULTANEOUS DOUBLE-SIDED PROBING

The Pegasus™ A200D series offers simultaneous, double-sided probing of up to 200 mm (8") wafers in a compact and easy to use fully automatic probing platform.

It delivers advanced automation for high volume probing of power devices.



### THE DESIGN

### AUTOMATIC DOUBLE-SIDED PROBE STATION FOR 200 MM WAFERS

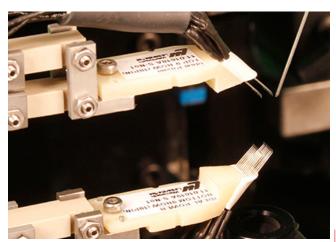
The Pegasus™ A200D series offers simultaneous, double-sided probing of up to 200 mm (8") wafers in a compact and easy to use fully automatic probing platform. It delivers advanced automation for high volume probing of power devices.

The A200D features highly developed upper and lower probe arm calipers which can be synchronized to contact the top and bottom side of the wafer at the same time using multiple needle probe cards. A proprietary mechanism ensures a constant pre-set needle load.

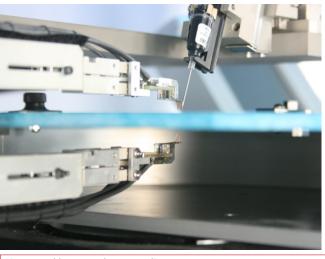


An extensive range of control and monitoring parameters enable users to operate Pegasus™ A200D probers at peak performance, including:

- Menu-driven, push button control via proprietary LabMaster™ Pro control and monitoring software
- ✓ Real-time monitoring and test setup
- Yield analysis of both the wafer and batch under test
- Premium mapping capability
- Image analysis
- Configurable to voltages up to 10 kV for specialized applications
- Optional thermal chuck capability



Probe cards for double sided probing

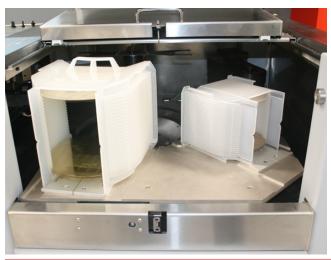


Upper and lower probe arm calipers

### HIGHLY ADVANCED CALIPERS FOR SIMULTANEOUS WAFER CONTACT

Articulated parallelogram motion of the probe tips ensures that the probes accommodate any deviation in wafer flatness.

Kelvin contacts can be used for source and drain to accurately measure resistances and remove lead voltage drop.



Wafer handler

Using proprietary wafer ring clamping chucks, the prober has a capacity to load from two cassettes, each containing up to 25 wafers.

### USER INTERFACE

#### LABMASTER™ CONTROL & MONITORING SOFTWARE

LabMaster™ Pro is a simple-to-use Windows based graphical interface which allows real-time, fully integrated monitoring and control. It integrates with LabVIEW™ and other industry standard platforms and controls the Pegasus™ prober via either an RS232 interface or a GPIB (IEEE488.2) interface using the National Instruments PCI-GPIB board.

#### **Wafer Map**

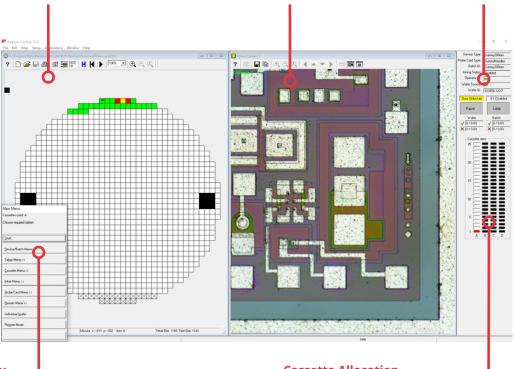
LabMaster™ Pro provides the capability of being able to import wafer map files or create new libraries on-the-fly. With 256 bin allocations and numerical or color die identification possible, the wafer map module provides great flexibility.

#### **Video Window**

Primarily used by the A200 series probers to run the PR solution for wafer alignment, LabMaster™ Pro can also be switched to live video for probe mark inspection, ink dot inspection as well as pin-to-pad alignment.

#### **Prober Status**

Key prober parameters can be easily monitored via the prober status window. Device types, batch details and probe card reference numbers are all recorded along with easy pause buttons. Percentage completion logs are also available.



#### Main Menu

The LabMaster™ Pro menu system provides protected access to all set-up of the A200D, programming and run functionality. From the operator access to start, stop and make simple process changes, to the engineer access to run adhoc wafer test or diagnostics, the A200D provides simple but intuitive menus.

#### **Cassette Allocation**

Most probers have facilities to mount two cassettes whereas LabMaster™ Pro can process up to four. Using automatic cassette scanning by the wafer handler, the slots will highlight if a wafer has been detected within a given slot. The tracking is dynamic, so if users wish to use different cassettes for tested and untested wafer, the occupied slots will be highlighted.

#### **OFFLINE TOOLS**

The Wentworth Laboratories' **Wafer Map Editor** is an offline editor/viewer for LabMaster™ compatible wafer map files and wafer map file templates. It allows for wafer map templates to be created and modified prior to being used for wafer testing. Wafer result files can also be viewed in this application and used to generate further template files.

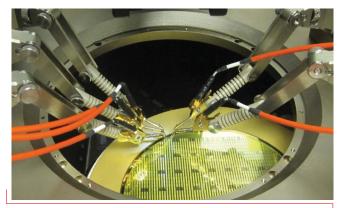
## LEADING EDGE APPLICATIONS

#### HIGH POWER

A high power configuration addresses today's power semiconductor test challenges with low contact resistance measurements requiring accuracy at high voltages.

Kelvin chucks and reverse side probing solutions allow contact resistance measurements in the milliohm range.

High current probes and probe cards (up to 100 A) handle and distribute excessive current loads. Dedicated HV and HC probes reduce probe and device destruction at high voltages/currents by preventing arcing at the tip.



High power test

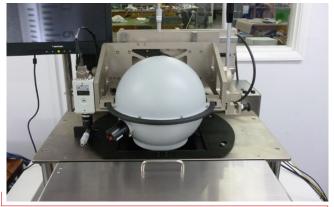
SPECIFICATIONS		
Voltage	10 kV (coax)	
Current	200 amps (pulsed)	

#### **OPTO ELECTRONICS**

Our FA series probers can be specifically designed for production sampling and analytical probing of semiconductor light emitting diodes (LEDs), laser diodes and optical MEMS devices.

Chuck solutions allow handling of full wafers, shards, single chips and packaged parts.

The set-up can accommodate spectrometer probes, fibre optics, integrating spheres, glass chucks, thermal imaging cameras and more.



Opto electronics test

#### **SPECIFICATIONS**

Reverse emission Glass chuck, reverse side

# OPTIONS & ACCESSORIES

MICROSCOPE MOUNTS						
Туре	Travel X/Y	Travel Z	Resolution	Drive	Recommended Microscope	Application
Manual stereozoom (MMM)	50x50 mm	50 mm*	0.9 μm	High precision lead screws	Binocular or trinocular stereozoom microscope	General probing, pad sizes down to 50 μm x 50 μm
Manual high powered (MMM)	50x50 mm	75 mm quicklift + 50 mm**	0.9 μm	High precision lead screws	Compound high mag objective microscope	Small geometry pad or line probing down to 1-2 µm
Programmable (PMM)	50x50 mm	100 mm + 50 mm**	0.1 μm	Stepper motors	Compound high mag objective microscope	Small geometry pad or line probing down to 1-2 μm

<sup>\*</sup>achieved through standard stereozoom focus arm

<sup>\*\*</sup> when using heavy duty focus block

MICROSCOPES		
Microscope Type	Models Available	Application
Stereo zoom	Wentworth, Leica	Pad probing and internal features down to 5 μm
High magnification	Mitutoyo FS-70 Series	Offers the most flexibility and options for features down to 0.5 $\mu m$
Without eyepieces	A-Zoom micro	Use with CCD or video systems.

COMMUNICATION INTERFACES		
Туре	Vendors	
TTL	(2) 15-way D plugs each providing (4) TTL signal outputs & (8) TTL inputs	
RS232	Serial 9-pin D connector	
GPIB (IEEE488.2)	8-bit parallel multi-master interface bus	
Ethernet	48-bit MAC address	

ACCESSORIES	
Probes: Triaxial, coaxial, low impedance, Kelvin, high power	<b>Automatic 2-point align:</b> Provides system automation and fast device set-up routine
<b>Probe tips:</b> Tungsten, Tungsten-Carbide, Be Cu, gold plated	<b>Pattern recognition:</b> Automatic die detection and probe to pad alignment
<b>Camera and monitors:</b> Facilitates contacting bond pads or taking images	Supplies: Vacuum pumps and air compressors
Interface panels: Coax BNC, triax BNC, SHV, HV triax, D-SUB, SSMA, SMB, banana	LabMaster™ Pro: Control and monitoring graphical user interface
Probe cards: Blade, custom solutions	Quiet Mode: Removes power to all motors to reduce the noise floor

## SPECIFICATIONS

#### PEGASUS™ A200D DOUBLE-SIDED PROBE STATION

	PROBER	
Chuck Stage		
X-Y Stage		
Туре	High precision recirculating ball screws	
Stage travel	210 x 210 mm (8.3 x 8.3")	
Resolution	1.25 µm	
Repeatability	± 4.0 μm	
Accuracy	± 7.0 μm over 200 mm	
Planarity	8.0 µm	
Maximum speed	100 mm/sec	
Automatic alignment repeatability	± 5.0 μm	
Caliper Arm Assem	bly	
Туре	Stepper motor drive, linear bearings	
Total travel	11.4 mm	
Repeatability	<6.0 μm	
Resolution	2.0 µm	
Theta Stage		
Precision ball-screw	s & stepper motors	
Travel	± 8.0°	
Resolution	0.2 μm, 0.0001° measured at edge of 200 mm (8") chuck	
Graphical User Inte	erface	
	Windows 7, 8.1 and 10	
Communication In	terfaces	
PC	TTL, RS232, GPIB (IEEE488.2), ETHERNET	
Utilities		
Power	100-240 VAC; 50/60 Hz auto select; 600 VA	
Vacuum	0.5 cfm @ 208 mm (20") Hg (min)	
Dimensions (w x d x h)		
Excludes monitor, lights & optics	1,420 x 850 x 1,080 mm (55.9 x 33.5 x 42.5")	
Weight		
	400 kg (882 lbs)	

	WAFER CARRIER
Sizes available	75 mm (3.0") 100 mm (4.0") 150 mm (6.0") 200 mm (8.0")
Planarity	Over 200 mm, 12 μm

	WAFER HANDLER	
Configuration		
Wafer Size	Up to 450 mm (17.8")	
Arm configuration(s)	2 link: 133.4–133.4 mm (5.25–5.25") 2 link: 184.2–184.2 mm (7-25–7.25") 3 link: 101.6–203.2–101.6 mm (4–8–4")	
End effectors types	Vacuum, edge-gripping, gravity	
Wafer mapping	Reflective; through-beam	
Physical Properti	es	
Size (diameter/ length)	247.9 mm (9.76") body DIA/ 768.4 mm (30.25")	
Vertical stroke- body height	177.8-345.4 mm (7.0-13.6") 304.8-472.4 mm (12.0-18.6") 431.8 -599.4 mm (17.0-23.6") 508-675.6 mm (20.0-26.6")	
Axes	3 - T, R, Z	
Range of motion	T: 500° R: 160–160 cm (5.25'-5.25') 221–221 cm (7.25'-7.25') 101.6–203.2–101.6 mm (4–8–4") Z: 177.8; 304.8; 431.8; 508 cm (7;12;17;20")	
Performance		
Payload (dynamic/static)	907 g (2 lbs)	
Repeatability	T: +/- 0.01° R: +/- 0.001" Z: +/- 0/001"	
Environment		
Cleanliness	ISO class 1 compatible	
Wafer contact material	Vespel, peek, teflon impregnated anodized Al, alumina, stainless steel	

### ABOUT US

#### A LEADING AUTHORITY IN FLEXIBLE PROBING SOLUTIONS SINCE 1967

Wentworth Laboratories is a leader in performance wafer probe stations and advanced cantilever probe cards. In close association with our customers, we play a pivotal role in the conception and development of cost-effective, productivity-enhancing wafer probing solutions for the semiconductor device test market. Our ability to craft customised and integrated wafer test solutions, with meticulous project communication and post-project monitoring, is second to none.

Our standard cantilever products accommodate blade and epoxy technology for a range of applications such as memory, RF and logic probe cards. Engineered solutions offer an impressive array of cantilever products for high voltage, extreme high and low temperatures and an unprecedented portfolio of bespoke products. We also offer design services for high speed, digital, analogue, mixed signal and memory applications.

Our global team supports probe card and wafer probing projects with sophisticated design, proven technology, experienced applications and technical support. Wentworth wafer prober products have been selected for many leading-edge wafer test applications across the semiconductor technology landscape, culminating in such products as hand-held devices, video game stations, PCs and medical diagnostic equipment, amongst others. As award-winning wafer test industry innovators, we are skilled in delivering wafer probers and cantilever probe card solutions that enable our customers to maximise their productivity and reduce cost.

The company was founded in 1967, has global representation and manufactures two major product lines. In our UK facilities, we manufacture wafer probers and cantilever probe cards whilst in the US, we manufacture cantilever probe cards and needle holder assemblies.



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